

DOCKET NO.: 285995US26PCT



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:

GROUP: 2812

Kohei KAWAMURA, et al.

SERIAL NO: 10/567,733

ATTENTION:  
FILING RECEIPT CORRECTIONS

FILED: February 10, 2006

FOR: METHOD FOR FORMING FILM, METHOD FOR MANUFACTURING SEMICONDUCTOR DEVICE, SEMICONDUCTOR DEVICE AND SUBSTRATE TREATMENT SYSTEM

**REQUEST FOR CORRECTED OFFICIAL FILING RECEIPT**

Office of Initial Patent Examination  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

The Patent Office is requested to provide a corrected Official Filing Receipt for the following.

PLEASE NOTE THAT THE NUMBER OF DRAWINGS IS INCORRECT. IT SHOULD READ AS FOLLOWS:

DRAWINGS: 9

PLEASE NOTE THAT THE APPLICANT'S CITY IS INCORRECT. IT SHOULD READ AS FOLLOWS:

KOHEI KAWAMURA, NIRASAKI-SHI, JAPAN

YASUO KOBAYASHI, NIRASAKI-SHI, JAPAN

KENICHI NISHIZAWA, NIRASAKI-SHI, JAPAN

YASUHIRO TERAI, NIRASAKI-SHI, JAPAN

AKIRA ASANO, NIRASAKI-SHI, JAPAN

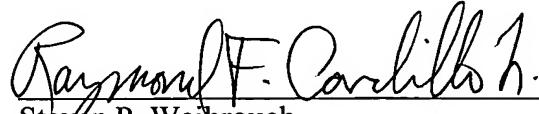
PLEASE NOTE THAT THE ASSIGNMENT FOR PUBLISHED PATENT APPLICATION DATA IS MISSING. IT SHOULD READ AS FOLLOWS:

**TOKYO ELECTRON LIMITED, MINATO-KU, JAPAN**

No fees are required. If you have any questions, please do not hesitate to contact us.

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND,  
MAIER & NEUSTADT, P.C.



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285995US-2459-2312-26-PCT  
10/567,733

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SERIAL NO: 10/567,733



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| APPL NO.   | FILING OR 371<br>(c) DATE | ART UNIT | FIL FEE REC'D | ATTY.DOCKET NO | DRAWINGS | TOT CLMS | IND CLMS |
|------------|---------------------------|----------|---------------|----------------|----------|----------|----------|
| 10/567,733 | 02/10/2006                | 2812     | 1300          | 285995US26PCT  | 1<br>9   | 17       | 5        |

22850  
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ALEXANDRIA, VA 22314

## FILING RECEIPT



\*OC000000019442715\*

Date Mailed: 07/07/2006

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

## Applicant(s)

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ASSIGNMENT FOR PUBLISHED PATENT APPLICATION

TOKYO ELECTRON LIMITED, MINATO-KU, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 22850.

## Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/10484 07/23/2004

## Foreign Applications

JAPAN 2003-293904 08/15/2003

If Required, Foreign Filing License Granted: 06/29/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/567,733**

Projected Publication Date: 10/05/2006

Non-Publication Request: No

Early Publication Request: No

**Title**

Method for forming film, method for manufacturing semiconductor device, semiconductor device and substrate treatment system

**Preliminary Class**

438

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**Title 37, Code of Federal Regulations, 5.11 & 5.15**

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